



Letter

Crystallographic data of new ternary Sm_5Ge_4 -type $\text{Gd}_2\text{Sc}_3\text{Ge}_4$ and $\text{R}_2\text{Sc}_3\text{Si}_4$ compounds (R=Sm, Gd–Tm)

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Received 6 May 1998; received in revised form 6 July 1998

Abstract

Investigations made by powder X-ray diffraction on eight new ternary $\text{Gd}_2\text{Sc}_3\text{Ge}_4$ and $\text{R}_2\text{Sc}_3\text{Si}_4$ compounds (R=Gd–Tm) are reported. The following compounds were observed to crystallize in the orthorhombic Sm_5Ge_4 -type structure (space group $Pnma$): $\text{Gd}_2\text{Sc}_3\text{Ge}_4$ ($a=0.7211(2)$ nm, $b=1.4050(6)$ nm, $c=0.7453(3)$ nm), $\text{Sm}_2\text{Sc}_3\text{Si}_4$ ($a=0.7094(1)$ nm, $b=1.3992(4)$ nm, $c=0.7402(2)$ nm), $\text{Gd}_2\text{Sc}_3\text{Si}_4$ ($a=0.7092(2)$ nm, $b=1.4012(4)$ nm, $c=0.7412(2)$ nm), $\text{Tb}_2\text{Sc}_3\text{Si}_4$ ($a=0.7078(1)$ nm, $b=1.3982(3)$ nm, $c=0.7395(2)$ nm), $\text{Dy}_2\text{Sc}_3\text{Si}_4$ ($a=0.7060(1)$ nm, $b=1.3951(4)$ nm, $c=0.7380(2)$ nm), $\text{Ho}_2\text{Sc}_3\text{Si}_4$ ($a=0.7042(1)$ nm, $b=1.3921(4)$ nm, $c=0.7362(2)$ nm), $\text{Er}_2\text{Sc}_3\text{Si}_4$ ($a=0.7028(1)$ nm, $b=1.3894(4)$ nm, $c=0.7343(2)$ nm) and $\text{Tm}_2\text{Sc}_3\text{Si}_4$ ($a=0.7011(2)$ nm, $b=1.3852(5)$ nm, $c=0.7324(2)$ nm). © 1998 Elsevier Science S.A. All rights reserved.

Keywords: Ternary rare earths compounds; Silicides; Germanides; Structure type

This paper reports on the structural data of eight new compounds using powder X-ray diffraction analysis.

In the present investigation the compounds were made in an electric arc furnace under an argon atmosphere using a non-consumable tungsten electrode and a water-cooled copper tray. Silicon (purity, 99.99%), germanium (purity, 99.99%), scandium (purity, 99.99%), samarium (purity, 99.99%), gadolinium (purity, 99.99%), terbium (purity, 99.99%), dysprosium (purity, 99.99%), holmium (purity, 99.98%), erbium (purity, 99.98%) and thulium (purity, 99.99%) were used as the starting components. Titanium was used as a getter during the melting process. The compounds were annealed at 1070 K for 200 h in argon atmosphere with titanium chips and quenched in ice-cold water.

X-ray powder diffraction analyses were obtained on an DRON-3.0 (Cu $K\alpha$ -radiation, $2\theta=20 \dots 70^\circ$). The obtained diffractograms were identified via calculated X-ray patterns which were obtained in the isotropic approximation using the Rietan-programs [1].

Eight new compounds have been detected: $\text{Gd}_2\text{Sc}_3\text{Ge}_4$, $\text{Sm}_2\text{Sc}_3\text{Si}_4$, $\text{Gd}_2\text{Sc}_3\text{Si}_4$, $\text{Tb}_2\text{Sc}_3\text{Si}_4$, $\text{Dy}_2\text{Sc}_3\text{Si}_4$,

$\text{Ho}_2\text{Sc}_3\text{Si}_4$, $\text{Er}_2\text{Sc}_3\text{Si}_4$ and $\text{Tm}_2\text{Sc}_3\text{Si}_4$. Analysis of the powder X-ray diffractograms shows that these compounds crystallize in the orthorhombic Sm_5Ge_4 -type structure ($Pnma$) [2] (Table 1). The lattice parameters of the compounds, refined at room temperature, and the reliability factor R_F resulting from the refinements are given in Table 2. The Sc atoms occupy the atomic positions of Sm2 and Sm3 in the Sm_5Ge_4 -type structure.

The dependencies of the lattice parameters of the $\{\text{Sm}, \text{Gd-Tm}\}_2\text{Sc}_3\text{Si}_4$ compounds of the Sm_5Ge_4 type on the crystallographic radii R of the low temperature modification of the corresponding rare-earth metals [3] are presented in Fig. 1.

Table 1
Atomic position parameters of $\text{Ce}_2\text{Sc}_3\text{Si}_4$ (Sm_5Ge_4 structure type; space group $Pnma$) [2,4]

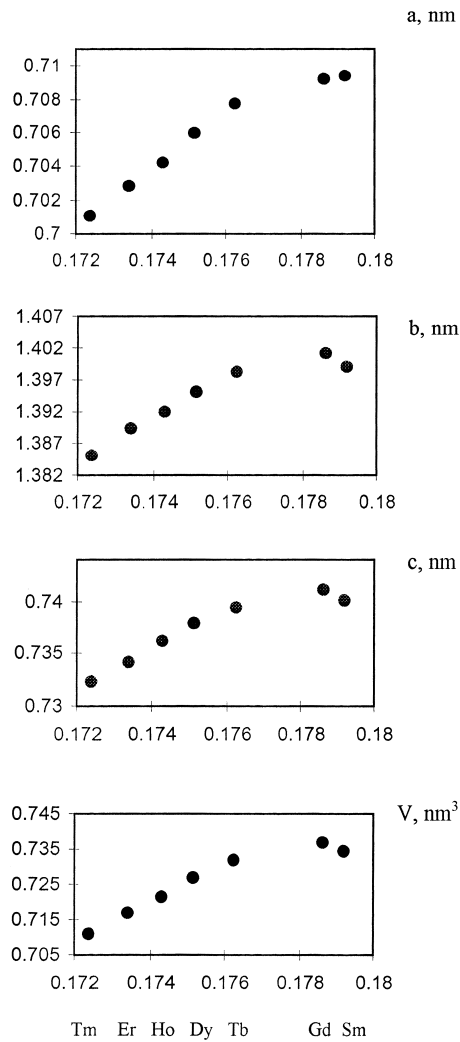
Atom	Type position	x/a	y/b	z/c
Ce	8(d)	0.1040	0.0971	0.8879
Sc1	4(c)	0.3392	1/4	0.9984
Sc2	8(d)	0.1716	0.1240	0.3248
Si1	4(c)	0.2123	1/4	0.6191
Si2	4(c)	0.9673	1/4	0.1241
Si3	8(d)	0.1533	0.9611	0.5367

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Table 2

Lattice parameters a , b , c (nm) and unit cell volume V (nm³) of the Gd₂Sc₃Si₄ and R₂Sc₃Si₄ (R=Sm, Gd–Tm) compounds^a

Compound	Structure	a	b	c	V	R_F
Sm ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7094(1)	1.3992(4)	0.7402(2)	0.73472	8.1
Gd ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7092(2)	1.4012(4)	0.7412(2)	0.73683	6.7
Tb ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7078(1)	1.3982(3)	0.7395(2)	0.73183	7.9
Dy ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7060(1)	1.3951(4)	0.7380(2)	0.72690	8.6
Ho ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7042(1)	1.3921(4)	0.7362(2)	0.72173	9.5
Er ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7028(1)	1.3894(4)	0.7343(2)	0.71700	8.5
Tm ₂ Sc ₃ Si ₄	Sm ₅ Ge ₄	0.7011(2)	1.3852(5)	0.7324(2)	0.71121	8.6
Gd ₂ Sc ₃ Ge ₄	Sm ₅ Ge ₄	0.7211(2)	1.4050(6)	0.7453(3)	0.75504	8.4

^a The R_F factor is given in %.Fig. 1. Dependence of the cell parameters of the {Sm, Gd–Tm}₂Sc₃Si₄ compounds on the R crystallographic radius.

The lattice parameters a , b , c and the cell volume V are proportional to the crystallographic radius of the rare earth metals for all rare earths excepting Sm.

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